

All references considered - /HC/

EAST Search History**EAST Search History (Prior Art)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	1	"10578879"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S2	6	(arscott near2 steve).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S3	2	(le near2 gac near2 severine).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S4	0	S3 not S2	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S5	8	(druon near2 christian).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S6	6	S5 not S2	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S7	7	(rolando near2 christian).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S8	2	S7 not S6 not S2	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S9	31	(universite near2 des near2 sciences near2 et near2 technologies).as.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47

S10	30	S9 not S8 not S6 not S2	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S11	0	S10 and (tip needle nozzle). clm.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S12	2	"5165601".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S13	3	"6602472".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S14	3109	(250/288).ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S15	2213	S14 and (@ad<"20041110" @rlad<"20041110")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S16	564	S15 and (ESI or (electro near2 spray near2 (interface ionization)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S17	69	S16 and ((wafer substrate (micro near2 chip)) with (tip nozzle needle capillary))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S18	30	S17 and hydrophobic	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:47
S19	3082	(250/281).ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO	OR	ON	2010/08/24 14:50

S20	2786	(250/282).ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO	OR	ON	2010/08/24 14:50
S21	975	(S19 S20) and (ESI or (electro near2 spray near2 (interface ionization)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:50
S22	48	S21 and ((wafer substrate (micro near2 chip)) with (tip nozzle needle capillary))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:50
S23	15	S22 and hydrophobic	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:50
S24	6	S22 and @py<"2004"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:51
S25	3	S23 and @py<"2004"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT	OR	ON	2010/08/24 14:51

EAST Search History (Interference)

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8/24/2010 2:52:13 PM**C:\Documents and Settings\hchang\My Documents\EAST\Workspaces\10578879.wsp**